

GEMOLOGICAL INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

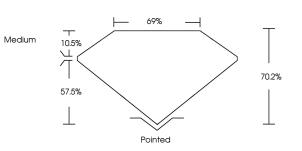
Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

| May 5, 2024 | |
|-------------------------|--------------------------|
| IGI Report Number | LG632443668 |
| Description | LABORATORY GROWN DIAMOND |
| Shape and Cutting Style | PRINCESS CUT |
| Measurements | 7.90 X 7.88 X 5.53 MM |
| GRADING RESULTS | |
| Carat Weight | 2.89 CARATS |
| Color Grade | E |
| Clarity Grade | VS 2 |
| ADDITIONAL GRADING I | NEORMATION |

ADDITIONAL GRADING INFORMATION

| Polish | EXCELLENT |
|----------------|-------------------|
| Symmetry | EXCELLENT |
| Fluorescence | NONE |
| Inscription(s) | 1/571 LG632443668 |

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process and may include post-growth treatment. Type IIa



LG632443668

Report verification at igi.org



Sample Image Used

COLOR

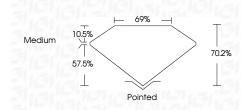
| D E F | GHIJ | Faint | Very Light | Light |
|------------------|--------------------------|----------------------|-------------------|---------------|
| CLARITY | WS ^{1 - 2} | VS ¹⁻² | SI ¹⁻² | 1-3 |
| IF Internally | VVS Very Very | VS | Slightly | I Included |
| Flawless | Slightly Included | Slightly Included | Included | |
| | | | | |
| | | | | |
| | | CITAN BURNEL | | តរនា |
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| © I | GI 2020, International G | emological Institute | | FD - 10 20 |
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DIAMOND REPORT

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| | |
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